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Atty. Docket No. 30205/39509 - Serial No. 10/722,815

Inventors: Cheol Kyu Bok et al.

Title: Overcoating Composition for Photoresist and Method

for Forming Photoresist Pattern Using the Same

Sheet 1 of 9

INCREASE OF EXPOSURE ENERGY









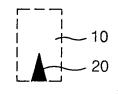


Fig.1 (Prior Art) Atty. Docket No. 30205/39509 - Serial No. 10/722,815 Inventors: Cheol Kyu Bok et al. Title: Overcoating Composition for Photoresist and Method

for Forming Photoresist Pattern Using the Same

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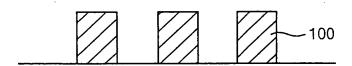


Fig.2a

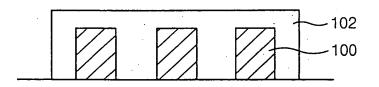


Fig.2b

Atty. Docket No. 30205/39509 - Serial No. 10/722,815 Inventors: Cheol Kyu Bok et al. Title: Overcoating Composition for Photoresist and Method for Forming Photoresist Pattern Using the Same

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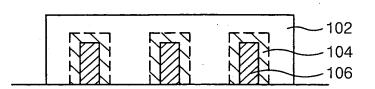


Fig.2c



Fig.2d

Atty. Docket No. 30205/39509 - Serial No. 10/722,815 Inventors: Cheol Kyu Bok et al. Title: Overcoating Composition for Photoresist and Method for Forming Photoresist Pattern Using the Same

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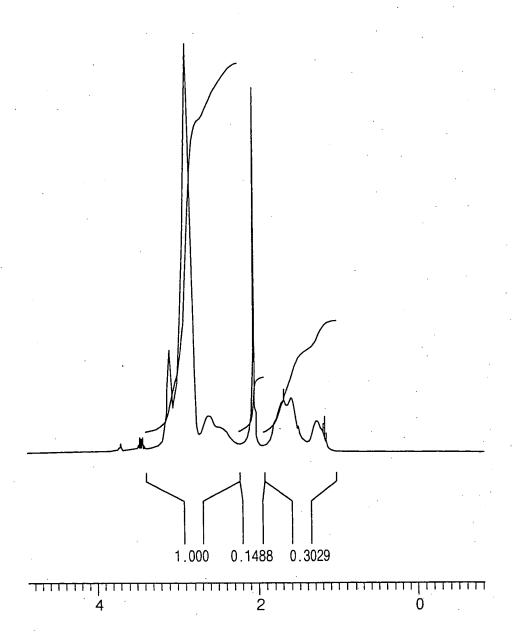


Fig.3

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Inventors: Cheol Kyu Bok et al.
Title: Overcoating Composition for Photoresist and Method for Forming Photoresist Pattern Using the Same Sheet 5 of 9

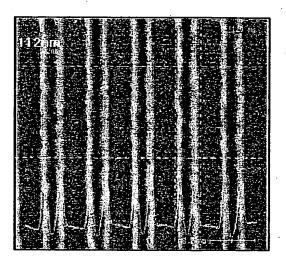


Fig.4a

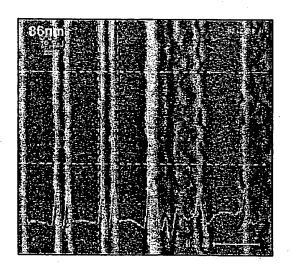


Fig.4b

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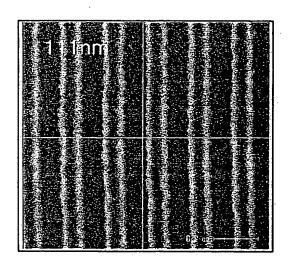


Fig.5a

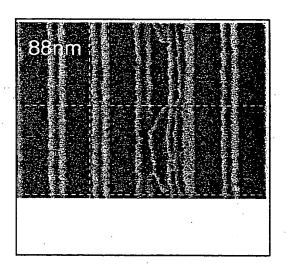


Fig.5b

Atty. Docket No. 30205/39509 - Serial No. 10/722,815 Inventors: Cheol Kyu Bok et al. Title: Overcoating Composition for Photoresist and Method for Forming Photoresist Pattern Using the Same Sheet 7 of 9

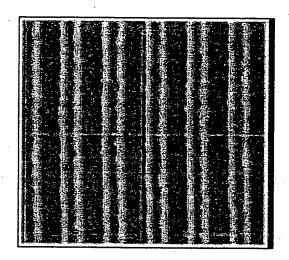


Fig.6a

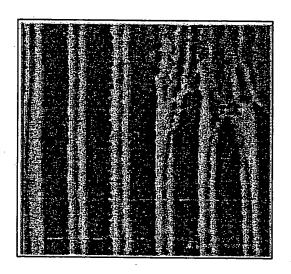


Fig.6b

Atty. Docket No. 30205/39509 - Serial No. 10/722,815 Inventors: Cheol Kyu Bok et al. Title: Overcoating Composition for Photoresist and Method for Forming Photoresist Pattern Using the Same Sheet 8 of 9

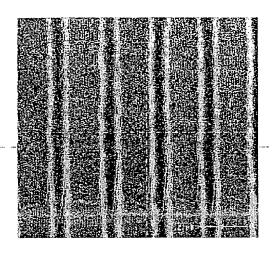


Fig. 7a

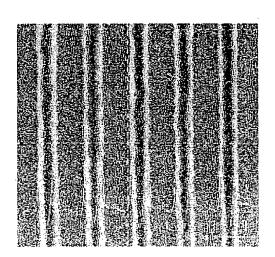


Fig. 7b

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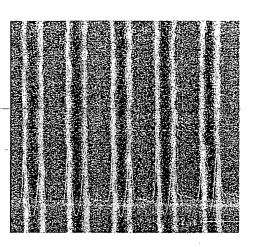


Fig. 8a

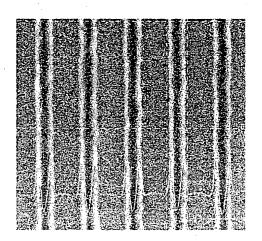


Fig. 8b